Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
Ľ1	33	(438/553).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/09/19 11:03
S1	7	tipro	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:18
S2	799	(mask or masking) and lithography and ligand	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:28
S3	297	titanium and S2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/24 08:40
S4	70	isomer and S3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2005/01/24 08:50
S5		("6348239").PN.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/24 08:50
S6	1	("5534312").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2005/01/24 08:53
S7	25	("5534312").URPN.	USPAT	OR ·	ON	2005/01/24 08:55
S8	15	("4770590" "5140366" "5178989" "5272099" "5292558" "5436176" "5534312" "5627087" "5652166" "5716758" "5935762" "5989759" "6072207" "6307087" "6387012").PN.	US-PGPUB; USPAT; USOCR	OR .	ON	2005/01/24 08:59

S9	154	(mask or masking) and lithography and ligand and nano	US-PGPUB; USPAT; EPO; JPO; DERWENT;	OR	ON	2005/01/24 12:21
			IBM_TDB			
S10	48	titanium adj diisopropoxide and acetoacetate	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/24 12:49
S11	1	("5534312").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/02/03 14:23
S12	29	("5534312").URPN.	USPAT	OR	ON	2006/02/03 14:28
S13	6933	remove adj exposed	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 12:50
S14	16	((mask or masking) and lithography and ligand) and S13	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:34
S15	10112	positive adj resist	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:34
S16	158258	ligand	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:34
S17	173	S15 and S16	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:34
S18	71267	remove near4 exposed or removed near4 exposed or removing near4 expose or removing near4 exposure or remove near4 exposure or removed near4 exposure	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:43

		<u></u>		,		
S19	. 2386	S15 and S18	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:43
S20	66	S16 and S19	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 14:43
S21	7559	protic adj solvent	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:00
S22	762909	exposure	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01
S23	1235	S21 and S22	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01
S24	4384166	√metal ·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01
S25	4454808	metal or ligand	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01
S26	1093	S23 and S25	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01

C27	3001706	light or ourselves or ourselves	HC DCDUD	OD	ON	2006/02/02 15:01
S27	3981786	light or exposure or exposing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:01
S28	1093	S26 and S27	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:02
S29	613103	mask or masking	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:02
S30	184	S28 and S29	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:12
S31	84	fury.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:20
S32	1790	maloney.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2006/02/03 15:20
S33	271271	precursor	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:20
S34	4384166	metal ·	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:20

					,	
S35	149533	S33 and S34	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:20
S36	25	S32 and S35	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:23
S37	959	svendsen.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/02/03 15:24
S38	41	S35 and S37	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:30
S39	6	hohertz.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/02/03 15:34
S40	10	bravo-vasquez.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:36
S41	203	ekc.as.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:36
S42	1	S13 and S41	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/03 15:36

S43	144	pmod or photochemical adj metal adj organgic adj deposition	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 12:13
S44	6933	remove adj exposed	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 12:50
S45	4896	mask and S44	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 12:50
S46	429	precursor and S45	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/02/04 12:50
S47	2	("6696363").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/09/19 09:47
S48	. 2	("20040126711").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2006/09/19 09:47
S49	15	("4770590" "5140366" "5178989" "5272099" "5292558" "5436176" "5534312" "5627087" "5652166" "5716758" "5935762" "5989759" "6072207" "6307087" "6387012").PN.	US-PGPUB; USPAT; USOCR	OR	ON	2006/09/19 09:48
S50	0	tipro2eaa2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:18

		, , , , , , , , , , , , , , , , , , , ,		·		
S51	7	tipro	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:19
S52	· 17	eaa2	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:27
S53	16718	pag or photo adj acid adj generator	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:27
S54	173538	ligand	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR .	ON	2006/09/19 10:27
S55	2555	S53 and S54	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR ·	ON	2006/09/19 10:28
S56	189902	isomer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:28
S57	400	S55 and S56 ,	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON .	2006/09/19 10:28
S58	1713693	ti or titanium	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON ·	2006/09/19 10:28

S59	189	S57 and S58	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:29
S60	1727178	semiconductor .	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:29
S61	65	S59 and S60	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:40
S62	28	(precursor and (develop or developed or developing) and metal and pattern and substrate and removing).clm.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2006/09/19 10:41